## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant:

Jerome M. Eldridge et al.

Title:

ATOMIC LAYER DEPOSITION OF METAL OXIDE AND/OR LOW ASYMMETRICAL

TUNNEL BARRIER INTERPLOY INSULATORS

Docket No.:

1303.045US1

Serial No.:

10/081,818

Filed:

February 20, 2002

Due Date:

November 8, 2008

Examiner:

Tu-Tu Ho

Group Art Unit:

2818

Customer No.:

73115

Confirmation No.: 3148

Notice of Allowance Date:

August 8, 2008

## Mail Stop Issue Fee

Commissioner for Patents

P.O. Box 1450

Alexandria, VA 22313-1450

We are transmitting herewith the following:

- Authorization to charge Deposit 19-0743 in the amount of \$110.00 to cover the issue fee increase.
- Issue Fee Transmittal (Form PTOL-85).
- Request to Apply Previously Paid Issue Fee (1 pg.)
- $\frac{X}{X}$   $\frac{X}{X}$   $\frac{X}{X}$ Communication Re: Fee Address (1 page).
- Communiction Concerning Related Applications (1 pg
- Supplemental Information Disclosure Statement Under CFR 1.97(i) (3 pgs)

Please charge any additional required fees or credit overpayment to Deposit Account No. 19-0743.

SCHWEGMAN, LUNDBERG & WOESSNER, P.A.

Customer No.: 73115

TBC:CMG:ker1

Timothy B. Clise

Reg. No. 40,957

CERTIFICATE UNDER 37 CFR 1.8: The undersigned hereby certifies that this correspondence is being filed using the USPTO's electronic filing system EFS-Web, and is addressed to: Mail Stop Issue Fee, Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450 on this day of November, 2008.